Enhance The Gas-Sensing Performances Of Graphene Oxide (GO) Thin Films For Detecting Nitrogen Dioxide Gas

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Enhance the gas-sensing performances of graphene oxide (GO) thin films for detecting nitrogen dioxide gas

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**Abstract**

In this work, graphene oxide (GO) synthesized via a modified Hummer method was utilized to manufacture thin films for gas sensor applications. The films were prepared on glass substrates using the spin coating technique, the concentration of GO was varied in the precursor liquid. The crystallographic properties of the prepared GO films were analyzed using XRD and the results showed a polycrystalline structure with a crystallite size of 15.51 nm. Using the weighing method, the average film thickness was determined to be about 200 nm. UV-Vis absorption spectrometry combined with the Tauc method confirmed the indirect nature (allowed and forbidden) of electronic transitions in the samples and it also showed a decrease in the optical energy gap with an increasing amount of GO in the samples. Values for Eg ranged from 2.4 eV to 2.15 eV for allowed transitions and from 3.05 eV to 2.6 eV for forbidden transitions. Gas sensing measurements were performed using NO2 as target gas at different operating temperatures (50, 100, 200 and 300 oC), as well as four target gas concentration (100 ppm, 400 ppm, 700 ppm, and 1000 ppm) have been tested and shows the good response in the range of 10%. It can be seen that the sensitivity increases with increasing operating temperature and gas concentration. At 300 oC operating temperature response and recovery time decrease to their lowest value or 2.6 and 5 seconds, respectively.

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1. Introduction

The technological improvement as well as growing environmental and health concerns have generated significant interest in detection of toxic and hazardous gases and the development of sensing equipment. Gas sensors are devices that convert a given gas concentration into the corresponding electrical signal. Sensors play an important role in a variety of industries and applications, such as chemical processing, environmental monitoring, agriculture, public safety, and medicine. Rising global demand to provide the gas sensor with high sensitivity, high selectivity, fast response, low cost, low
power consumption, high stability, and portability has led to the search for new gas-sensing materials. [9-6]. Graphene, first described by Geim and Novoselov [19], exhibits a particularly intriguing two-dimensional structure consisting of sp2 hybridized carbon atoms. Graphene is considered the thinnest material in the world [4], a one-atom-thick sheet forming a hexagonal lattice with a thickness of approximately 0.335 nm, a carbon-carbon bond length of 0.142 nm, and a bond angle of 120°.

The distinctive structure of graphene gives rise to its unique properties, such as excellent thermal and electrical conductivity, high strength and it further allows for the quantum Hall effect to be observable at room temperature. Additionally, graphene features a large surface area which is beneficial for adsorption [25].

The oxidized form of graphene (GO) is also a two-dimensional material with oxygen functional groups. The large interest in this material is a result of its exceptional properties. The presence of oxygen functional groups makes graphene oxide hydrophilic and allows it to be dispersed in aqueous solutions. This allows for easy processing when combining it with other materials in order to improve electrical and mechanical properties [24]. Furthermore, the size of the graphene oxide layer can be tuned from mm-range down to a few nm. This tunability of both its flake size and chemical composition through doping makes graphene oxide an attractive material in many fields such as electronic applications, composite materials, clean energy devices, biology, and medicine [2].

It was found in both, experimental and theoretical work [5], that graphene and its derivatives, such as graphene oxide, present not only a large specific surface area facilitating the gas molecules adsorption, but also an easily modifiable surface, allowing for the gas sensing ability to be tuned. Presently, there is an increased focus on enhancing the performance of graphene gas sensors using computational chemistry, composite materials, and micro-electro-mechanical systems.

2. Sensing Properties

Graphene has an electronic bandgap of zero. However, adding elements such that oxygen which results in formation of holes in the carbon lattice result in p-type semiconducting behavior [26]. This change in the Fermi level caused by p-type doping, on the one hand, causes a change in the adsorption energy, where the introduced holes cause an electron to pull effect towards atoms and molecules in the gas atmosphere, and the other hand it leads to changes in the electrical conductivity of graphene. This effect is sensitive not only to p-type but also n-type doping and makes graphene an ideal material to detect adsorbed gas molecules. Whether an adsorbed atom or molecule will act as a donor or an acceptor is determined by the relative position of the Fermi level of graphene compared to the valence band of the adsorbed species, e.g. is the Fermi surface of graphene lower than the valence band of the adsorbed molecule, it works as donor and when the Fermi surface of graphene is higher than the valence band, the adsorbed species works as acceptor [29]. The change in resistivity of graphene is dependent on the concentration of adsorbed species, which allows it to be used in field effect transistors (FET) and MEMS gas sensors. In those devices, a substrate, made of an insulating material, is coated with graphene as the gas-sensing material, and electrodes are deposited at both ends of the sensitive material. Most commonly, gas sensors operate in resistive mode, where the concentration of a certain gas is analyzed by directly measuring the change of resistance during interaction with a given atmosphere [8].
3. Experimental Procedure

In this work, graphene oxide (GO) was produced based on the modified Hummers method from pure graphite. 2.3 g of graphite and 1.2 g of sodium nitrate (NaNO3) were mixed, then 100 ml of sulphuric acid (H₂SO₄) and 0.005 gm of boric acid (H₃BO₃) were added and the mixture was stirred over an ice bath for 15 min. This was followed by progressively adding 5 gm of potassium permanganate (KMnO₄) while maintaining the temperature at 0°C. The resulting solution was stirred for 2 more hours until it turned dark green. This mixture was left for another 2 hours to react, then the temperature was raised to 40°C for 30 min. Then, 100 ml of deionized water was slowly added, together with a rapid temperature increase to 100°C. After 5 minutes, the solution was treated with 7.5 ml H₂O₂ before being washed and rinsed with deionized water and a 5% HCl solution. Finally, the reaction product was dried at 60°C, resulting in powdered graphene oxide.

Preparing GO concentrations have been doing it by solving (0.1, 0.2, 0.3, and 0.4 gm) of graphene oxide and in (10) ml of the deionized water and mix them using a magnetic stirrer to get a homogeneous solution. The spin coating method was used to deposit GO thin films on a glass substrate equipped with a grid of aluminum electrodes, Figure 1. Time and spin speed were adjusted to get a homogeneous film with the required thickness. Determination of film thickness was performed by using the weighing method according to the following formula:

$$ t = \frac{\Delta m}{\rho A} $$

(1)

Where $\Delta m$ is the mass difference of the substrate before and after the deposition process, A (25mm×15mm) is the coated area and $\rho$ (0.44gm/cm³) is the mass density.

Figure 1: A Schematic diagram of aluminum electrode grid deposited on the sensor substrate (glass).
X-ray diffraction (wavelength $\lambda = 1.5406\text{Å}$) was utilized to gather crystals graphic information about the GO films. The distance between adjacent lattice planes ($d$) was calculated using the Bragg equation [17,21]:

$$n\lambda = 2d \sin \theta$$  \hspace{1cm} (2)

The diffraction pattern shown in Figure 2 was used to determine the average crystallite size ($D$) according to the Scherrer equation [11,6]:

$$D = \frac{0.9\lambda}{\beta \cos \theta}$$  \hspace{1cm} (3)

Where $\lambda$ is the X-ray wavelength, $\theta$ is the Bragg angle and $\beta$ is the line broadening at full-width half-maximum (FWHM).

![X-ray diffraction pattern for thin GO films deposited on glass.](image)

UV–vis absorption spectroscopy measurements were performed with a UV-1650PC Shimadzu spectrophotometer to estimate the energy gap. Light intensity attenuation across the film follows the Lambert-Beer law [16,11]:

$$l = l_0 e^{-\alpha x}$$  \hspace{1cm} (5)
Where $I$ and $I_0$ are the intensity of light before and after passing through the film, $\alpha$ is the absorption coefficient and $x$ the film thickness.

The data of absorption coefficient versus wavelength shown in (Figure 3) were used to estimate the optical energy gap ($E_g$) using Tauc’s equation [1,13]:

$$\frac{\alpha(h\nu)}{B^{1/r}} = (h\nu - E_g)^{1/r}$$

(4)

Where $B$ is the Tauc constant, $h\nu$ is the photon energy, $\alpha$ is the absorption coefficient, $r$ is a constant related to the density of states distribution and indicates the type of transition so that its value will be equal to 1/2 for direct allowed transitions and $3/2$ for direct forbidden transitions, while $n$ takes a value of 2 for indirect allowed transitions and 3 for indirect forbidden transitions.

The energy band gap describes the difference in energy between the bottom of the conduction band and the top of the valence band, thus band gap tuning is an important factor to optimize the performance of the optoelectronic materials [28].

3. Results

The thickness of the films was calculated using equation 1, an average of 200 mm film thickness was chosen. After applying the top electrodes, the films were transferred into the manufactured gas sensor testing system is shown in Figure 1. The bias voltage was set to 10 volts and the chamber pressure was chosen to be in the range of $1 \times 10^{-2}$ bar. A flow meter was used to control the desired gas/air ratio in the testing chamber. To connect the sensor to the electric circuit, aluminum electrodes were thermally deposited on the coated slides via a thermal evaporation system (Edwards E306A Coating System). The electrode pattern is illustrated in Figure 2, its shape is designed to provide the maximum possible contact area between the electrode and the sensing material. The response of sensor towards exposure to gas has been checked by calculating the sensor sensitivity ($S$) which is defined as [22]:

$$S = \frac{R_{gas} - R_o}{R_o} \times 100\%$$

(6)

Where $R_{gas}$ and $R_o$ are the resistances of the sensor when exposed to the target gas (NO2) and without gas respectively.

The XRD diffraction pattern shown in Figure 3 confirms the polycrystalline nature of the GO films. The most prominent peak at 2 theta angles of 11.6° reveals a crystallite size of 15.51 nm and a d space of 0.75 nm. These results are in good agreement with (00-024-0072), International Center for Diffraction Data (ICDD) cards, and other published articles, [20,15]. The Tauc method, described in equation 4, allows for the calculation of the energy bandgap using data gained from optical absorbance.
spectra. Where the optical absorption strength is dependent on the difference between the energy band gap and photon energy. The value of the exponent depends on the nature of the electronic transition, which can be either direct or indirect. The calculated values for $[(\alpha h\nu)]^{1/2}$ and $[(\alpha h\nu)]^{1/3}$ versus $(h\nu)$ were plotted in Figures (4 and 5). In the calculations, the value of the exponent was chosen in order to provide the best fit and thus helps in identifying the type of transition. The energy band gap (Eg) for each sample was determined via the intercept of the linear portion of each curve with the $h\nu$ axis. The obtained values for the energy gap compared with the different amount of GO are listed in Table (1). It is worth noting that a decrease in the optical energy gap with an increasing weight percentage of GO in the sample can be seen, which can be resulting from an increase in the available energy localized levels near the band edges. These results are in agreement with [12].

![Figure 3](image-url)

**Figure 3**: Variation $(\alpha h\nu)^{1/2}$ versus $h\nu$, for allowed indirect transition (a), for forbidden indirect transition (b), at different amount of GO in the sample.
Table 1: The values of energy gap for the allowed and forbidden indirect transitions compared to varying amount of GO.

<table>
<thead>
<tr>
<th>GO (wt%)</th>
<th>Energy gap (eV)</th>
</tr>
</thead>
<tbody>
<tr>
<td></td>
<td>Allowed</td>
</tr>
<tr>
<td>1</td>
<td>2.4</td>
</tr>
<tr>
<td>2</td>
<td>2.31</td>
</tr>
<tr>
<td>3</td>
<td>2.25</td>
</tr>
<tr>
<td>4</td>
<td>2.15</td>
</tr>
</tbody>
</table>

4. Gas Sensing Tests

The gas sensing tests were performed in a gas chamber, which was manufactured from acrylic plastic and heated using a small ceramic heater connected to a temperature controller. The chamber is supplied with the target gas (NO2) and air using two mass flow meters, set to a constant flow of 1000 sccm during the sensing measurements. A current source (2400 Source Meter, Keithley, Cleveland, Ohio, USA) was joined to a computer and used to measure the electrical resistance of the samples. The change in resistance in the GO films resulting from adsorbed gas molecules was translated into an electrical signal by the sensor and could be used to detect or calculate the target gas concentration. The measurement set-up is shown in Figure 4.

Measurements were conducted for the target gas (NO2) concentrations in a preset range (100 ppm, 400 ppm, 700 ppm, and 1000 ppm) and various operating temperatures (50, 100, 200, and 300oC), which is defined as the temperature where the resistance reaches a constant value. Figure 6 shows the variation of sensor sensitivity to operating temperature and it can be seen that the sensitivity increases with increasing operating temperature to an optimum of 250oC, that can be interpreted as due to the increased reaction rate between the sample surface and target gas. The response and recovery times of the sensor as a function of operating temperature for the sample with 4% concentration of GO are shown in Figure 5. Both, response and recovery time of this sensor decrease with increasing operating temperature, down to the lowest responsive and recovery time of about 2.6 s and 5 s, respectively.
Table (2): Response and recovery time vs graphene oxide concentration.

<table>
<thead>
<tr>
<th>GO wt%</th>
<th>Response time (s)</th>
<th>Recover time (s)</th>
</tr>
</thead>
<tbody>
<tr>
<td>1</td>
<td>7.3</td>
<td>25.2</td>
</tr>
<tr>
<td>2</td>
<td>5.2</td>
<td>20.3</td>
</tr>
<tr>
<td>3</td>
<td>4.4</td>
<td>17.2</td>
</tr>
<tr>
<td>4</td>
<td>2.6</td>
<td>05.0</td>
</tr>
</tbody>
</table>

Figure 4: Experiment setup, gas sensor testing system.
Figure 5: Variation of sensor sensitivity for NO2 with operating temperature for different percent of GO

Figure 6 indicates a rapid increase in the sensor response with NO2 gas concentrations. This level of sensitivity and performance make it a favorable material to make reliable sensors. The high sensitivity and fastest response times could be realized at a gas concentration of 1000 ppm, which is in good agreement with [14,10]. NH3 acts as an electron donor on graphene. Therefore, when the GO film is exposed to NH3 molecules, electrons will be easily transferred to GO thin film, thereby reducing the number of conductive holes and, thus increasing the electrical resistance of GO film. While, NO2 gas and graphene working together as an electron acceptor. When the surface of graphene absorbs NO2 molecule, electrons will be transferred from the graphene to the NO2 molecule, which lead to increases the hole concentration in the graphene and therefore decrease the resistance [7].

Figure 6: The dependence of GO sensor sensitivity on NO2 gas concentrations.
5. Conclusion

In this work, the influence of varying amounts of graphene oxide (GO) (1-4 wt%) on the performance of thin film gas sensors have been investigated. Properties analyzed were sensitivity, response and recovery time. The thin film samples have furthermore undergone XDR analysis and UV-Vis spectroscopy. XRD diffraction patterns revealed a polycrystalline structure of GO. Moreover, the most prominent peak at a 2 theta angle of 10.6° was used to calculate the crystallite size using the Scherer equation. The results indicate a crystallite size of 15.51 nm in the films. Tauc analysis of the optical absorption spectra shows that the electronic transition is indirect and the energy gap about 2.4 eV to 2.15 eV for allowed transitions and from 3.05 eV to 2.6 eV for forbidden transitions. The GO films exhibited good sensitivity and selectivity to the target gas, NO2. The quickest response-recovery characteristics (2.6 and 5 s, respectively) and the highest sensitivity were found at 200oC operating temperature. Finally, the findings in this work and encouraging results in using GO thin films to accurately sense NO2 gas suggest that more research into the improvement and production of such sensing devices is needed.

References:


